Enhancement of Corrosion Resistance of the Metallic Components Used in the IS Process — Exploring a Coating Material That Can Withstand a Sulfuric Acid Boiling Environment —



Fig.1 Change in corrosion rate with increasing corrosion time for samples, and Cr element mapping of the coating or matrix cross section in SUS304 coated with S-ZAC and MS-ZAC

The corrosion resistance of SUS304 coated with MS-ZAC after 100 h is confirmed to be equivalent to that of SiC. Cross-sectional microstructural observation of this material after corrosion testing shows fine Cr, AI, and Si particles of size less than 5 μ m.

The iodine–sulfur (IS) process, which is a thermochemical hydrogen production method, is a heat application technology in HTGRs. This requires structural components with excellent heat and corrosion resistance. In particular, the sulfuric acid decomposer, in which liquid sulfuric acid is transformed into a boiling state, has the most severely corrosive environment in the IS process. Therefore, SiC ceramics are yet to be used. However, SiC sintering furnaces are restricted by size limitations, and it is difficult to scale up their components for commercial production.

Therefore, we considered the development of a metallic material with corrosion resistance equivalent to that of SiC by forming a dense film on the metal surface that can be easily scaled up. Test specimens were prepared from fluorine-coated SUS304 and SUS304 coated with high-density oxide slurry. The chemical densified coating method involves coating the matrix with a slurry of Cr₂O₃, Al₂O₃, and SiO₂ particles, followed by sintering at 500 °C–600 °C. We prepared S-ZAC, in which sintering was performed eight times, and MS-ZAC, in which sintering was performed 11 times to further densify the coating.

After the corrosion testing, the fluorine-coated material was completely delaminated. It exhibited a high corrosion rate after the 12 h test, as shown in Fig.1. Moreover, the S-ZAC-treated material maintained its corrosion resistance even after the 12 h test, but the coating peeled off after the 100 h test. However, the



Fig.2 (a) Cross-sectional microstructures of SUS304 coated with S-ZAC and MS-ZAC before the corrosion test, and (b) schematic diagram of S-ZAC under the corrosion test and MS-ZAC after the corrosion test

In S-ZAC, the tensile stress at the Cr_2O_3 –SiO₂ interface causes the curving of the thick film, which leads to film delamination. In MS-ZAC, the SiO₂ particles became finer and the voids became smaller, which enables maintaining a thin film.

highly densified MS-ZAC-treated material showed corrosion resistance comparable to that of SiC after the 100 h test. Cr element mapping of the coating and matrix cross sections after 100 h tests showed that S-ZAC disappeared, whereas the MS-ZAC remained dense with fine Cr, Al, and Si particles of size 5 μ m or less.

Fig.2(a) shows the cross-sectional microstructures of S-ZAC and MS-ZAC before the corrosion testing. Coarse SiO_2 aggregates and voids were observed in S-ZAC, whereas finer oxide particles, fewer voids, and thinner films were observed in MS-ZAC (Fig.2(b)).

Therefore, considering the condition of the film in the boiling sulfuric acid test environment, it is speculated that in S-ZAC, the Cr_2O_3 surrounding the SiO₂ began expanding, and tensile stress acted at the Cr_2O_3 –SiO₂ interface, causing the thick film to curve, leading to film delamination. In contrast, MS-ZAC maintained a thin film because the SiO₂ particles became finer during the impregnation process, resulting in smaller voids. In the future, we plan to study the thickening of the MS-ZAC films.

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Reference

Hirota, N. et al., Evaluation of Corrosion Resistance and Surface Film Analysis After Corrosion Testing of Materials Coated by Chemical Densified Coating Method Under Boiling Sulfuric Acid Environment, Journal of the Society of Materials Science, Japan, vol.72, no.3, 2023, p.255–261 (in Japanese).